

APW



PATENT
Attorney Docket No. 01197.0276-00

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
)	
Hiroshi YAMADA et al.)	Group Art Unit: 1795
)	
Application No.: 10/587,315)	Examiner: Vaughan II, Juan E.
)	
Filed: July 26, 2006)	
)	
For: PHOTSENSITIVE RESIN)	Confirmation No.: 4548
COMPOSITION FOR LASER)	
ENGRAVABLE PRINTING)	
SUBSTRATE (as amended))	

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

SUPPLEMENTAL AMENDMENT

Please amend this application to correct an error in the amendment filed

August 21, 2008:

Amendments to the Claims are reflected in the listing of claims in this paper.

Remarks follow the amendment sections of this paper.